

#28
02-26-03

PTO/SB/68 (04-01)

Approved for use through 10/31/2002. OMB 0651-0031

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REQUEST FOR ACCESS TO AN APPLICATION UNDER 37 CFR 1.14(e)

In re Application of <u>MOSS</u>	
Application Number <u>09/122484</u>	Filed <u>7/24/98</u>
Art Unit	Examiner

Paper No. _____

Assistant Commissioner for Patents
Washington, DC 20231

1. ☐ I hereby request access under 37 CFR 1.14(e)(2) to the application file record of the above-identified ABANDONED Application, which is not within the file jacket of a pending Continued Prosecution Application (CPA) (37 CFR 1.53(d)) and is: (CHECK ONE)

☒ (A) referred to in:

United States Patent Application Publication No. _____, page _____, line _____,

United States Patent Number 6160876, column _____, line _____, or

an International Application which was filed on or after November 29, 2000 and which

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☐ (B) referred to in an application that is open to public inspection as set forth in 37 CFR 1.11(b) or

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Deborah A. Beavers
Signature

Date

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